## IN THE CLAIMS:

Please amend the claims as shown below. The status of the claims after amendment will be as follows:

- 1. (currently amended) A lead-free solder alloy comprising consisting of 1.0 5.0 wt% Ag, 0.01 0.5 wt% Ni, at least one of (a) 0.001 0.05 wt% Co and (b) at least one of P, Ge, and Ga in a total amount of 0.001 0.05 wt%, and a remainder of Sn.
- 2. (currently amended) A lead-free solder alloy as claimed in claim 1 which comprises 1.0 5.0 wt% Ag, 0.01 0.5 wt% Ni, containing 0.001 0.05 wt% Co , and a remainder of Sn.
- 3. (currently amended) A lead-free solder alloy as claimed in claim 1 which comprises 1.0 5.0 wt% Ag, 0.01 0.5 wt% Ni, containing at least one of P, Ge, and Ga in a total amount of 0.001 0.05 wt% , and a remainder of Sn.
- 4. (currently amended) A lead-free solder alloy as claimed in claim 1 which comprises 1.0 5.0 wt% Ag, 0.01 0.5 wt% Ni, containing 0.001 0.05 wt% Co [[,]] and at least one of P, Ge, and Ga in a total amount of 0.001 0.05 wt%, and a remainder of Sn.
- 5. (original) A solder ball formed from the alloy of claim
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1047

- 6. (original) A solder paste comprising a solder powder of the alloy according to claim 1 mixed with a flux.
- 7. (original) A solder bump formed from the alloy of claim l.
- (original) An electronic part having a plurality of solder bumps formed from the alloy of claim 1.
- 9. (original) A method of joining two members comprising a step of forming a soldered joint using the alloy of claim 1.
  - 10. (new) A lead-free solder alloy as claimed in claim 1 containing 0.005 - 0.03 wt% Co.
  - 11. (new) A lead-free solder alloy as claimed in claim 1 containing at least one of P, Ge, and Ga in a total amount of 0.002 - 0.01 wt%.
- 12. (new) A lead-free solder alloy as claimed in claim 1 containing 0.02- 0.2 wt% Ni.